10799762_CLS.txt Most Frequently Occurring Classifications of Patents Returned From A Search of 10799762 on January 26, 2005

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Original Classifications
          430/280.1
313/512
430/312
Cross-Reference Classifications
          313/502
522/170
522/25
522/31
250/239
    4
    4
   252/301.36
          257/100
          264/137
264/495
264/496
          313/501
349/153
          385/92
427/553
          427/66
          430/270.1
          430/273.1
430/281.1
430/288.1
430/315
430/319
          430/325
          430/327
430/945
473/378
522/100
522/15
          522/29
           522/99
          526/222
528/409
528/90
Combined Classifications
5 313/502
5 522/170
    4
          522/25
          522/31
    43333333322222222
          264/496
313/512
385/92
          430/270.1
430/280.1
          430/280.1

430/312

430/315

156/273.3

250/239

250/551

252/301.36

257/100
          257/98
          264/137
264/495
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10799762_CLS.txt

2 313/501 2 313/503 2 349/153 2 385/88 2 427/553 2 427/66 2 428/457 2 428/690 2 430/273.1 2 430/281.1 2 430/319 2 430/325 2 430/327 2 430/327 2 430/945 2 473/378 2 522/100 2 522/15 2 522/28 2 522/29 2 522/29 2 526/222 2 528/409 2 528/90

10799762_CLSTITLES.txt Titles of Most Frequently Occurring Classifications of Patents Returned From A Search of 10799762 on January 26, 2005

3	lass 313 313/483 313/498	OR, 4 XR) : ELECTRIC LAMP AND DISCHARGE DEVICES WITH LUMINESCENT SOLID OR LIQUID MATERIAL . Solid-state type
3	313/502	With phosphor embedding material
5 522/17 C	0 (1 Class 522	OR, 4 XR) : SYNTHETIC RESINS OR NATURAL RUBBERS PART OF THE CLASS 520 SERIES
5	522/1	COMPOSITIONS TO BE POLYMERIZED BY WAVE ENERGY WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL; OR COMPOSITIONS TO BE MODIFIED BY WAVE ENERGY WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL; OR PROCESSES OF PREPARING OR TREATING A SOLID POLYMER UTILIZING WAVE ENERGY
5	522/168	Processes of preparing a solid polymer from a heterocyclic chalogen monomer; or compsitions therefore
5	22/170	1,2 epoxy
4 522/25 C	(0 Class 522	
5	522/1	OF THE CLASS 520 SERIES .COMPOSITIONS TO BE POLYMERIZED BY WAVE ENERGY WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL; OR COMPOSITIONS TO BE MODIFIED BY WAVE
ENERGY		
SOLID		WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL; OR PROCESSES OF PREPARING OR TREATING A
5	522/6	POLYMER UTILIZING WAVE ENERGYCompositions to be polymerized or modified by wave energy wherein said composition contains at least
one		specified rate-affecting material; or processes of preparing or treating a solid polymer utilizing wave
energy		in the presence of at least one specified
rate-affect	ing	material; e.g., nitrogen containing photosensitizer,
oxygen		containing photoinitiator, etc. wave energy in order to prepare a cellular product
5	522/7	Contains two or more rate-affecting materials, at least one of which is specified
5	522/25	Specified rate-affecting material contains onium group
4 522/31 C	l (1 Class 522	
5	522/1	OF THE CLASS 520 SERIES .COMPOSITIONS TO BE POLYMERIZED BY WAVE ENERGY WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL; OR COMPOSITIONS TO BE MODIFIED BY WAVE ENERGY WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL; OR PROCESSES OF PREPARING OR TREATING A SOLID
5	522/6	POLYMER UTILIZING WAVE ENERGY Compositions to be polymerized or modified by wave energy wherein said composition contains at least
one		3,

one

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10799762_CLSTITLES.txt
                              specified rate-affecting material; or processes of
                              preparing or treating a solid polymer utilizing wave
energy
                              in the presence of at least one specified rate-affecting
                              material; e.g., nitrogen containing photosensitizer,
oxygen
                              containing photoinitiator, etc. wave energy in order to
                              prepare a cellular product
                          ... Specified rate-affecting material contains
           522/31
                             onium group
  3 264/496
                     (1 OR, 2 XR)
                           PLASTIC AND NONMETALLIC ARTICLE SHAPING OR
          Class
                   264:
                            TREATING: PROCESSES
                          .Utilizing electrostatic charge, field, force (e.g., pinning, etc.)
.Polymerizing, cross-linking, or curing (e.g., utilizing ultraviolet radiation, etc.)
          264/484
          264/494
                          ..While contacting a shaping surface (e.g., in
          264/496
                             mold curing, etc.)
                     (2 OR, 1 XR)
  3 313/512
                   313 : ELECTRIC LAMP AND DISCHARGE DEVICES
          class
                          WITH LUMINESCENT SOLID OR LIQUID MATERIAL
           313/483
           313/498
                          .Solid-state type
           313/512
                          .. With envelope or encapsulation
                     (1 OR, 2 XR)
85 : OPTICAL WAVEGUIDES
    385/92
                    38̀5 :
           Class
           385/53
                          WITH DISENGAGABLE MECHANICAL CONNECTOR
           385/88
                          .Optical fiber to a nonfiber optical device
                              connector
           385/92
                          ..With housing
  3 430/270.1
                     (1 OR, 2 XR)
                           RADIATION IMAGERY CHEMISTRY: PROCESS,
           Class
                    430:
                            COMPOSITION, OR PRODUCT THEREOF
                          IMAGING AFFECTING PHYSICAL PROPERTY OF
           430/269
                               RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR OR
                               PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT
                          .Radiation sensitive composition or product or
           430/270.1
                             process of making
                     (3 OR, 0 XR)
  3 430/280.1
           Class
                    430 :
                           RADIATION IMAGERY CHEMISTRY: PROCESS,
                            COMPOSITION, OR PRODUCT THEREOF
                          IMAGING AFFECTING PHYSICAL PROPERTY OF
           430/269
                                RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR OR
                                PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT
                          .Radiation sensitive composition or product or
           430/270.1
                               process of making
                          ..Radiation sensitive composition comprising
           430/280.1
                             oxirane ring containing component
  3 430/312
                     (2 OR, 1 XR)
                           RADIATION IMAGERY CHEMISTRY: PROCESS,
           class
                    430 :
                          COMPOSITION, OR PRODUCT THEREOF IMAGING AFFECTING PHYSICAL PROPERTY OF
           430/269
                                RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR OR
                                PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT
           430/311
                          .Making electrical device
           430/312
                          .. Including multiple resist image formation
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10799762_CLSTITLES.txt
     430/315
                       (1 OR, 2 XR)
                             RADIATION IMAGERY CHEMISTRY: PROCESS,
            Class
                     430 :
                               COMPOSITION, OR PRODUCT THEREOF
            430/269
                            IMAGING AFFECTING PHYSICAL PROPERTY OF
                                    RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR
OR
                                    PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT
            430/311
                             .Making electrical device
            430/313
                             ... with formation of resist image, and etching
                                 of substrate or material deposition
            430/315
                             ... Material deposition only
                      (1 OR, 1 XR)
  2 156/273.3
                     156 : ADHESIVE BONDING AND MISCELLANEOUS CHEMICAL
            class
                               MANUFACTURE
            156/1
                            METHODS
            156/60
                             .Surface bonding and/or assembly therefor
            156/272.2
                             .. With direct application of electrical,
                             magnetic, or radiant energy to work
...Before final assembly; e.g., to cure lamina,
            156/273.3
                                etc.
  2 250/239
                       (0 OR, 2 XR)
                     250 : RADIANT ENERGY
            Class
            250/200
                            PHOTOCELLS; CIRCUITS AND APPARATUS .Housings (in addition to cell casing)
            250/239
     250/551
                       (1 \text{ OR}, 1 \text{ XR})
                     250 : RADIANT ENERGY
            Class
            250/200
250/551
                            PHOTOCELLS; CIRCUITS AND APPARATUS
                             .Signal isolator
    252/301.36
                      (0 \text{ OR}, 2 \text{ XR})
                     252 : COMPOSITIONS
            Class
            252/301.36
                            INORGANIC LUMINESCENT COMPOSITIONS WITH ORGANIC
                                NONLUMINESCENT MATERIAL
                       (0 \text{ OR}, 2 \text{ XR})
  2 257/100
                             ACTIVE SOLID-STATE DEVICES
            Class
            257/79
                            INCOHERENT LIGHT EMITTER STRUCTURE
            257/100
                             .Encapsulated
     257/98
                       (1 \text{ or}, 1 \text{ XR})
            Class
                     257 :
                             ACTIVE SOLID-STATE DEVICES
            257/79
                            INCOHERENT LIGHT EMITTER STRUCTURE
            257/98
                             .With reflector, opaque mask, or optical
                                element (e.g., lens, optical fiber, index of refraction matching layer, luminescent material layer, filter) integral with device or device enclosure or package
                      (0 OR, 2 XR)
  2 264/137
            class
                             PLASTIC AND NONMETALLIC ARTICLE SHAPING OR
                               TREATING: PROCESSES
                            WITH PRINTING OR COATING OF WORKPIECE (OUT OF
            264/129
                                   MOLD)
                             .Coating or impregnating workpiece before
            264/134
                             molding or shaping step
...Impregnation of batt, sheet, or filament
            264/136
            264/137
                             ... Heat settable impregnant
    264/495
                       (0 \text{ or}, 2 \text{ XR})
                     264 : PLASTIC AND NONMETALLIC ARTICLE SHAPING OR
            Class
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TREATING: PROCESSES

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10799762_CLSTITLES.txt
                        .Utilizing electrostatic charge, field, force
        264/484
                        (e.g., pinning, etc.)
.Polymerizing, cross-linking, or curing (e.g.,
        264/494
                        utilizing ultraviolet radiation, etc.)
..Indefinite length articles
        264/495
  313/501
                  (0 \text{ or}, 2 \text{ XR})
                 313 :
                       ELECTRIC LAMP AND DISCHARGE DEVICES
        Class
        313/483
                       WITH LUMINESCENT SOLID OR LIQUID MATERIAL
        313/498
                        .Solid-state type
                        ... Semiconductor depletion layer type
        313/499
        313/501
                        ...Light conversion
2 313/503
                  (1 \text{ OR}, 1 \text{ XR})
        Class
                 313 :
                        ELECTRIC LAMP AND DISCHARGE DEVICES
        313/483
                       WITH LUMINESCENT SOLID OR LIQUID MATERIAL
         313/498
                        .Solid-state type
                        .. with particular phosphor or electrode
         313/503
                           material
                  (0 OR, 2 XR)
  349/153
                 349:
                         LIQUID CRYSTAL CELLS, ELEMENTS AND SYSTEMS
        Class
        349/56
                        PARTICULAR STRUCTURE
                        .Having significant detail of cell structure
         349/84
                            only
        349/153
                        ..Liquid crystal seal
                  (1 OR, 1 XR)
85 : OPTICAL WAVEGUIDES
  385/88
                 385:
        Class
         385/53
                       WITH DISENGAGABLE MECHANICAL CONNECTOR
         385/88
                        .Optical fiber to a nonfiber optical device
                           connector
  427/553
                  (0 \text{ OR}, 2 \text{ XR})
                 427 : COATING PROCESSES
        Class
        427/457
                        DIRECT APPLICATION OF ELECTRICAL, MAGNETIC,
                             WAVE, OR PARTICULATE ENERGY
        427/532
                        .Pretreatment of substrate or post-treatment of
                            coated substrate
        427/553
                        ..Low energy electromagnetic radiation (e.g.,
                           microwave, radio wave, IR, UV, visible, actinic, laser,
2
                  (0 OR, 2 XR)
  427/66
        Class
                         COATING PROCESSES
         427/58
                        ELECTRICAL PRODUCT PRODUCED
         427/64
                        .Fluorescent or phosphorescent base coating
                            (e.g., cathode-ray tube, luminescent screen, etc.)
         427/66
                        ..Electroluminescent lamp
                  (1 OR, 1 XR)
  428/457
                         STOCK MATERIAL OR MISCELLANEOUS ARTICLES
                 428 :
        Class
         428/411.1
                        COMPOSITE (NONSTRUCTURAL LAMINATE)
         428/457
                        .of metal
  428/690
                  (1 OR, 1 XR)
                 428 :
                         STOCK MATERIAL OR MISCELLANEOUS ARTICLES
         class
         428/411.1
                        COMPOSITE (NONSTRUCTURAL LAMINATE)
         428/688
                        .Of inorganic material
                        .. Metal-compound-containing layer
         428/689
         428/690
                        ...Fluroescent, phosphorescent, or luminescent
                           layer
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10799762_CLSTITLES.txt
     430/273.1
                      (0 \text{ or, } 2 \text{ XR})
           Class
                     430 :
                             RADIATION IMAGERY CHEMISTRY: PROCESS,
                              COMPOSITION, OR PRODUCT THEREOF
           430/269
                            IMAGING AFFECTING PHYSICAL PROPERTY OF
                                   RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR
OR
                                   PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT
           430/270.1
                            .Radiation sensitive composition or product or
                            process of making
...Identified backing or protective layer
           430/271.1
                            containing ...Identified overlayer on radiation-sensitive
           430/273.1
                                laver
     430/281.1
                      (0 \text{ OR}, 2 \text{ XR})
           Class
                     430 :
                             RADIATION IMAGERY CHEMISTRY: PROCESS,
                              COMPOSITION, OR PRODUCT THEREOF
           430/269
                            IMAGING AFFECTING PHYSICAL PROPERTY OF
                            RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR OR PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT .Radiation sensitive composition or product or
           430/270.1
                                 process of making
           430/281.1
                            ..Radiation sensitive composition comprising
                                ethylenically unsaturated compound
    430/288.1
                      (0 \text{ OR}, 2 \text{ XR})
                             RADIATION IMAGERY CHEMISTRY: PROCESS,
            class
                     430 :
                              COMPOSITION, OR PRODUCT THEREOF
                            IMAGING AFFECTING PHYSICAL PROPERTY OF
            430/269
                                   RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR
OR
                                   PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT
                            .Radiation sensitive composition or product or
           430/270.1
                                  process of making
                            ..Radiation sensitive composition comprising
           430/281.1
                                 ethylenically unsaturated compound
           430/288.1
                            ...Plural, terminal unsaturation
  2
     430/319
                      (0 OR, 2 XR)
                     430 :
           Class
                             RADIATION IMAGERY CHEMISTRY: PROCESS,
                            COMPOSITION, OR PRODUCT THEREOF IMAGING AFFECTING PHYSICAL PROPERTY OF
            430/269
                                  RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR OR
                                  PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT
                            .Making electrical device ..Named electrical device
            430/311
            430/319
  2 430/325
                      (0 \text{ OR}, 2 \text{ XR})
                             RADIATION IMAGERY CHEMISTRY: PROCESS,
           class
                     430 :
                              COMPOSITION, OR PRODUCT THEREOF
                            IMAGING AFFECTING PHYSICAL PROPERTY OF
            430/269
                                  RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR OR
                                  PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT
                            .Forming nonplanar surface
            430/322
                            ..Post image treatment to produce elevated
            430/325
                                pattern
    430/327
                      (0 \text{ or}, 2 \text{ XR})
           class
                     430 :
                             RADIATION IMAGERY CHEMISTRY: PROCESS,
                               COMPOSITION, OR PRODUCT THEREOF
           430/269
                            IMAGING AFFECTING PHYSICAL PROPERTY OF
                                 RADIATION SENSITIVE MATERIAL, OR PRODUCING NONPLANAR OR PRINTING SURFACE - PROCESS, COMPOSITION, OR PRODUCT
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10799762_CLSTITLES.txt
          430/327
                          .Processing feature prior to imaging
  2 430/945
                     (0 \text{ OR}, 2 \text{ XR})
          Class
                   430 :
                           RADIATION IMAGERY CHEMISTRY: PROCESS,
                            COMPOSITION, OR PRODUCT THEREOF
          430/945
                          LASER BEAM
                     (0 OR, 2 XR)
  2
    473/378
          Class
                   473 :
                           GAMES USING TANGIBLE PROJECTILE
           473/131
                          GOLF
           473/351
                          .Ball
                          ..Particular cover (e.g., size, material, dimple pattern, etc.)
           473/378
  2 522/100
                     (0 \text{ OR}, 2 \text{ XR})
                    522 :
                           SYNTHETIC RESINS OR NATURAL RUBBERS -- PART
           Class
                            OF THE CLASS 520 SERIES
           522/1
                          .COMPOSITIONS TO BE POLYMERIZED BY WAVE ENERGY
                               WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING
                               MATERIAL; OR COMPOSITIONS TO BE MODIFIED BY WAVE ENERGY
                               WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING
                               MATERIAL; OR PROCESSES OF PREPARING OR TREATING A SOLID
                               POLYMER UTILIZING WAVE ENERGY
                          .. Processes involving an ethylenically
           522/100
                             unsaturated material derived from poly 1,2-epoxide as reactant or a solid polymer; or compositions thereof
  2 522/15
                     (0 \text{ OR}, 2 \text{ XR})
                    522 :
                           SYNTHÉTIC RESINS OR NATURAL RUBBERS -- PART
           class
                            OF THE CLASS 520 SERIES
           522/1
                          .COMPOSITIONS TO BE POLYMERIZED BY WAVE ENERGY
                                  WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING
                                  MATERIAL; OR COMPOSITIONS TO BE MODIFIED BY WAVE
ENERGY
                                  WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING
                                  MATERIAL: OR PROCESSES OF PREPARING OR TREATING A
SOLID
                                 · POLYMER UTILIZING WAVE ENERGY
                          ..Compositions to be polymerized or modified by
          522/6
                                 wave energy wherein said composition contains at least
one
                                 specified rate-affecting material; or processes of
                                 preparing or treating a solid polymer utilizing wave
energy
                                 in the presence of at least one specified
rate-affecting
                                 material; e.g., nitrogen containing photosensitizer,
oxygen
                                 containing photoinitiator, etc. wave energy in order
to
                                 prepare a cellular product
           522/7
                          ... Contains two or more rate-affecting
                                materials, at least one of which is specified
                          ....Contains compound containing keto group not part of a ring and a specified rate-affecting material;
           522/12
or
                               contains a specified rate-affecting material and a
                              nonspecified photoinitiator or photosensitizer
           522/15
                          .....Specified rate-affecting material contains
                             onium group
                   (1 OR, 1 XR)
522 : SYNTHETIC RESINS OR NATURAL RUBBERS -- PART
  2 522/28
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Class

10799762_CLSTITLES.txt OF THE CLASS 520 SERIES 522/1 .COMPOSITIONS TO BE POLYMERIZED BY WAVE ENERGY WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL; OR COMPOSITIONS TO BE MODIFIED BY WAVE **ENERGY** WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL: OR PROCESSES OF PREPARING OR TREATING A SOLID POLYMER UTILIZING WAVE ENERGY 522/6 ... Compositions to be polymerized or modified by wave energy wherein said composition contains at least one specified rate-affecting material; or processes of preparing or treating a solid polymer utilizing wave energy in the presence of at least one specified rate-affecting material; e.g., nitrogen containing photosensitizer, oxygen containing photoinitiator, etc. wave energy in order to prepare a cellular product ...Contains two or more rate-affecting 522/7 materials, at least one of which is specified Specified rate-affecting material contains 522/28 phosphorous, arsenic, antimony or nitrogen (0 OR, 2 XR) 22 : SYNTHETIC RESINS OR NATURAL RUBBERS -- PART 2 522/29 522: Class OF THE CLASS 520 SERIES 522/1 .COMPOSITIONS TO BE POLYMERIZED BY WAVE ENERGY WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL; OR COMPOSITIONS TO BE MODIFIED BY WAVE **ENERGY** WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL; OR PROCESSES OF PREPARING OR TREATING A SOLID POLYMER UTILIZING WAVE ENERGY 522/6 ... Compositions to be polymerized or modified by wave energy wherein said composition contains at least one specified rate-affecting material; or processes of preparing or treating a solid polymer utilizing wave energy in the presence of at least one specified rate-affecting material; e.g., nitrogen containing photosensitizer, oxygen containing photoinitiator, etc. wave energy in order to prepare a cellular product ...Contains two or more rate-affecting materials, at least one of which is specifiedSpecified rate-affecting material is a 522/7 522/29 metal-containing organic compound 2 522/99 (0 or, 2 XR)SYNTHETIC RESINS OR NATURAL RUBBERS -- PART class 522 : OF THE CLASS 520 SERIES .COMPOSITIONS TO BE POLYMERIZED BY WAVE ENERGY 522/1 WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING MATERIAL: OR COMPOSITIONS TO BE MODIFIED BY WAVE ENERGY WHEREIN SAID COMPOSITION CONTAINS A RATE-AFFECTING

POLYMER UTILIZING WAVE ENERGY

MATERIAL; OR PROCESSES OF PREPARING OR TREATING A SOLID

or	522/99	10799762_CLSTITLES.txtProcesses involving a polysiloxane having ethylenic unsaturation as reactant or as solid polymer;
or		compositions therefore
2	Class 526: SYNTHETIC RESINS OR NATURAL RUBBERS OF THE CLASS 520 SERIES	526 : SYNTHETIC RESINS OR NATURAL RUBBERS PART OF THE CLASS 520 SERIES
PROCESSES OF POLYME CONTAINING ONLY ETH PROCESSES OF PREPAR	PROCESSES OF POLYMERIZING, POLYMERIZABLE COMPOSITIONS CONTAINING ONLY ETHYLENIC MONOMERS AS REACTANTS OR PROCESSES OF PREPARING	
	526/89	Polymerizing in the presence of a specified material other than monomer
	526/222	
2	528/409 Class	(0 OR, 2 XR) 528 : SYNTHETIC RESINS OR NATURAL RUBBERS PART OF THE CLASS 520 SERIES
	528/403	.FROM HETEROCYCLIC REACTANT CONTAINING AS RING
	528/408	ATOMS OXYGEN, SELENIUM OR TELLURIUM, E.G., EPOXY, ETCPolymerizing in the presence of a specified
	528/409	material other than a reactantMaterial contains a metal atom
2	528/90 Class	(0 OR, 2 XR) 528: SYNTHETIC RESINS OR NATURAL RUBBERS PART
	528/86	OF THE CLASS 520 SERIES FROM PHENOL, PHENOL ETHER, OR INORGANIC
	528/87	PHENOLATEFrom 1,2-epoxy-containing phenolic reactant
	528/88	or with 1,2-epoxy-containing reactantPolymerizing in the presence of a specified material other than reactant
	528/90	material other than reactantMaterial contains a sulfur atom